

20 GHz to 40 GHz, Tunable Band-Pass Filter

FEATURES

- ▶ Amplitude settling time: 200 ns
- ▶ Wideband rejection: ≥ 40 dB
- ▶ Single-chip implementation
- ▶ 8-pad, $2.55\text{ mm} \times 1.18\text{ mm} \times 0.15\text{ mm}$, RoHS-compliant CHIP

APPLICATIONS

- ▶ Airport scanners
- ▶ Test and measurement equipment
- ▶ Military radar and electronic warfare systems
- ▶ Very small aperture terminal (VSAT) communications

GENERAL DESCRIPTION

The ADMV8440CHIPS is a monolithic microwave integrated circuit (MMIC), tunable band-pass filter that features a user-selectable pass-band frequency of operation. The center frequency (f_{CENTER}) typically varies between 19 GHz and 38 GHz by applying a center frequency control voltage (V_{FCTL}) between 0 V and 15 V. Additionally, the usable pass-band frequencies ($f_{\text{L}3\text{dB}}$ and $f_{\text{U}3\text{dB}}$) are specified from 20 GHz to 40 GHz.

FUNCTIONAL BLOCK DIAGRAM

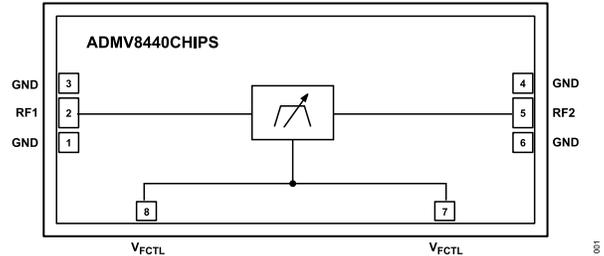


Figure 1.

The wideband rejection at half of the f_{CENTER} is typically 40 dB, which is ideally suitable for improving system level harmonic performance. This tunable filter is a smaller alternative to switched filter banks and cavity tuned filters. The ADMV8440CHIPS has minimal microphonics due to the monolithic design and provides a dynamically adjustable solution in advanced communications applications.

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REVISION HISTORY**8/2022—Revision 0: Initial Version**

SPECIFICATIONS

$T_A = 25^\circ\text{C}$ and center frequency control voltage (V_{FCTL}) is swept from 0 V to 15 V, unless otherwise noted.

Table 1.

Parameter	Min	Typ	Max	Unit	Test Conditions/Comments
CENTER FREQUENCY (f_{CENTER})		19		GHz	$V_{\text{FCTL}} = 0 \text{ V}$
		38		GHz	$V_{\text{FCTL}} = 15 \text{ V}$
USABLE PASS-BAND FREQUENCY			20	GHz	$V_{\text{FCTL}} = 0 \text{ V}$
Lower Pass-Band Frequency (f_{L3dB})				GHz	$V_{\text{FCTL}} = 15 \text{ V}$
Upper Pass-Band Frequency (f_{U3dB})	40			GHz	$V_{\text{FCTL}} = 15 \text{ V}$
BANDWIDTH (3 dB)		27		%	$V_{\text{FCTL}} = 7 \text{ V}$
LOSS					
Insertion Loss		7		dB	
Return Loss		10		dB	
WIDEBAND REJECTION ($\leq 60 \text{ GHz}$)					
Low Side at $0.5 \times f_{\text{CENTER}}$	40			dB	
High Side at $1.5 \times f_{\text{CENTER}}$	40			dB	
RE-ENTRY FREQUENCY		>67		GHz	$\leq 30 \text{ dB}$
DYNAMIC PERFORMANCE					
Input Power at 5° Shift in Insertion Phase		17		dBm	$V_{\text{FCTL}} = 0 \text{ V}$
Input Third-Order Intercept (IP3)		28		dBm	$V_{\text{FCTL}} = 7 \text{ V}$
Group Delay Flatness		0.05		ns	$V_{\text{FCTL}} = 7 \text{ V}$
Phase Sensitivity		1		Rad/V	$V_{\text{FCTL}} = 7 \text{ V}$
Amplitude Settling		200		ns	To within $\leq 0.5 \text{ dB}$ of static insertion loss
Drift Rate					
Amplitude		-0.012		dB/ $^\circ\text{C}$	$V_{\text{FCTL}} = 7 \text{ V}$
Frequency		-75		ppm/ $^\circ\text{C}$	$V_{\text{FCTL}} = 7 \text{ V}$
RESIDUAL PHASE NOISE					
1 MHz Offset		-157		dBc/Hz	$V_{\text{FCTL}} = 7 \text{ V}$
TUNING VOLTAGE (V_{FCTL})	0		15	V	
TUNING CURRENT (I_{FCTL})			± 1	mA	

ABSOLUTE MAXIMUM RATINGS

Table 2.

Parameter	Rating
Tuning	
V_{FCTL}	-0.5 V to +15 V
I_{FCTL}	±1 mA
RF Input Power	20 dBm
Temperature	
Operating Range	-55°C to +85°C
Storage Range	-65°C to +150°C
Junction to Maintain 1,000,000 Hours Mean Time to Failure (MTTF)	150°C
Nominal Junction ($T_{PADDLE}^1 = 85^\circ\text{C}$, Input Power (P_{IN}) = 20 dBm)	93°C

¹ T_{PADDLE} is the GND pad temperature.

Stresses at or above those listed under Absolute Maximum Ratings may cause permanent damage to the product. This is a stress rating only; functional operation of the product at these or any other conditions above those indicated in the operational section of this specification is not implied. Operation beyond the maximum operating conditions for extended periods may affect product reliability.

ELECTROSTATIC DISCHARGE (ESD) RATINGS

The following ESD information is provided for handling of ESD-sensitive devices in an ESD protected area only.

Human body model (HBM) per ANSI/ESDA/JEDEC JS-001-2011.

Field induced charged device model (FICDM) per JEDEC JESD22-C101E and ANSI/ESDA/JEDEC JS-002.

ESD Ratings for ADMV8440CHIPS

Table 3. ADMV8440CHIPS, 8-Pad Bare Die

ESD Model	Withstand Threshold (V)	Class
HBM	2500	2
FICDM	1250	C3

ESD CAUTION



ESD (electrostatic discharge) sensitive device. Charged devices and circuit boards can discharge without detection. Although this product features patented or proprietary protection circuitry, damage may occur on devices subjected to high energy ESD. Therefore, proper ESD precautions should be taken to avoid performance degradation or loss of functionality.

PIN CONFIGURATION AND FUNCTION DESCRIPTIONS

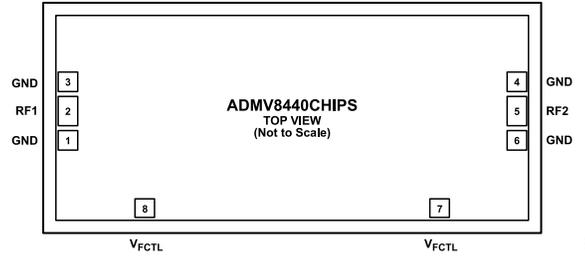


Figure 2. Pin Configuration

Table 4. Pin Function Descriptions

Pad No.	Mnemonic	Description
1, 3, 4, 6	GND	Ground. These pads can be connected to the RF and DC ground. The metallization of these pads is gold.
2	RF1	RF1. This pad is dc-coupled and matched to 50 Ω. Do not apply an external voltage to this pad. The metallization of this pad is gold.
5	RF2	RF2. This pad is dc-coupled and matched to 50 Ω. Do not apply an external voltage to this pad. The metallization of this pad is gold.
7, 8	V_FCTL	Center Frequency Control Voltage. These pads control the f _{CENTER} of the device. Connection to only one pad is necessary. The metallization of these pads is gold.
	Backside	Die Backside. The die backside must be connected to RF and DC ground. The die backside metallization is gold.

INTERFACE SCHEMATICS



Figure 3. GND Interface Schematic

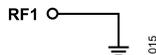


Figure 4. RF1 Interface Schematic

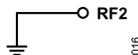


Figure 5. RF2 Interface Schematic

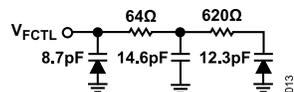


Figure 6. V_FCTL Interface Schematic

TYPICAL PERFORMANCE CHARACTERISTICS

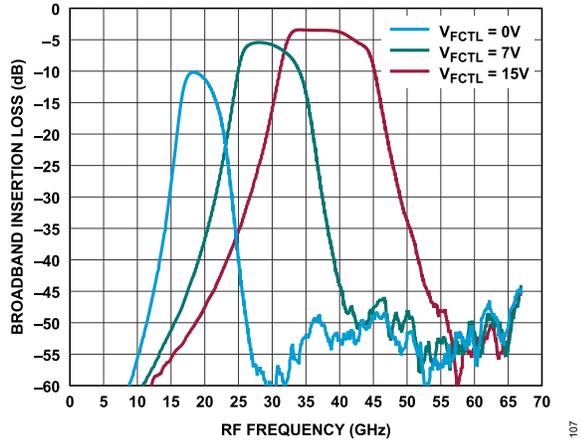


Figure 7. Broadband Insertion Loss vs. RF Frequency at Various Voltages

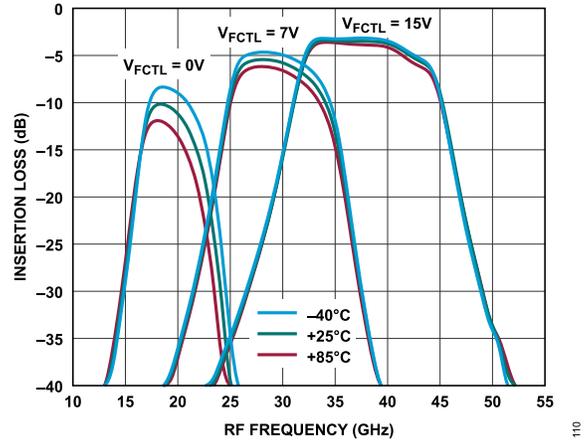


Figure 10. Insertion Loss vs. RF Frequency at Various Voltages and Temperatures

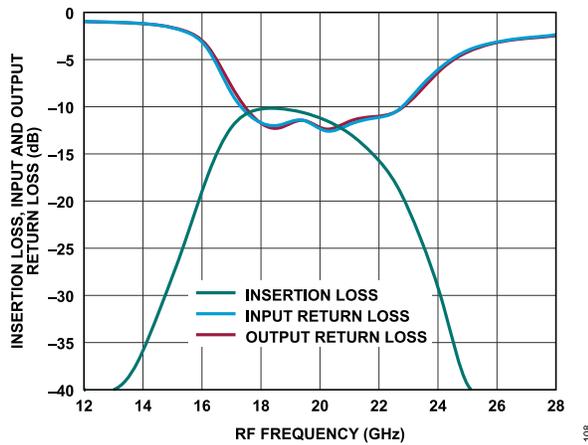


Figure 8. Insertion Loss, Input and Output Return Loss vs. RF Frequency at $V_{FCTL} = 0 V$

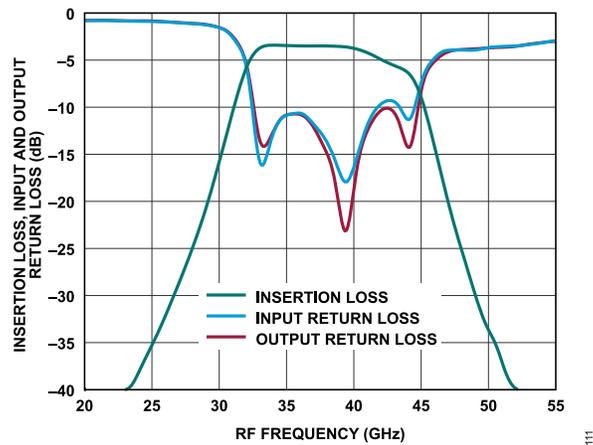


Figure 11. Insertion Loss, Input and Output Return Loss vs. RF Frequency at $V_{FCTL} = 15 V$

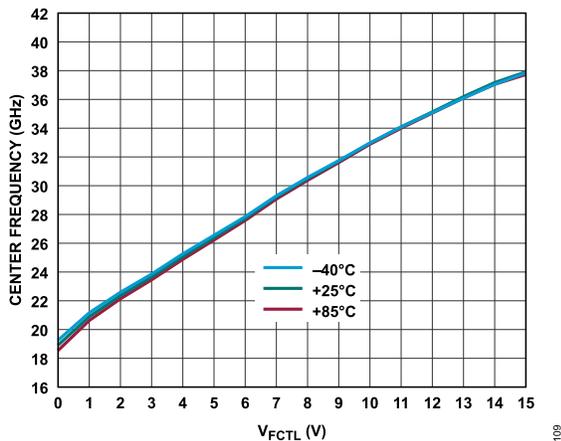


Figure 9. Center Frequency vs. V_{FCTL} at Various Temperatures

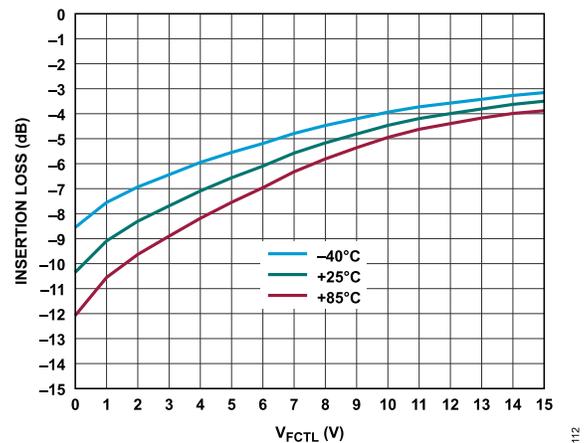


Figure 12. Insertion Loss vs. V_{FCTL} at Various Temperatures

TYPICAL PERFORMANCE CHARACTERISTICS

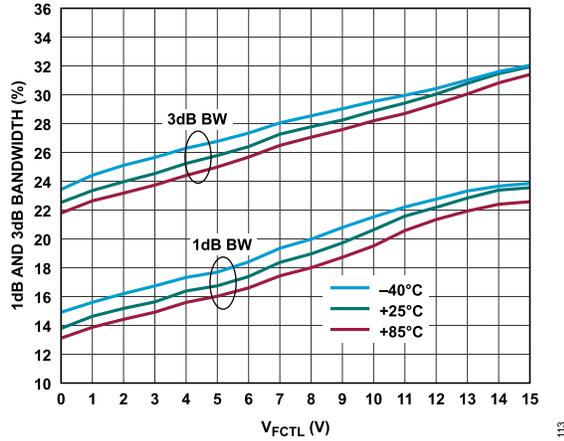


Figure 13. 1 dB and 3 dB Bandwidth vs. V_{FCTL} at Various Temperatures

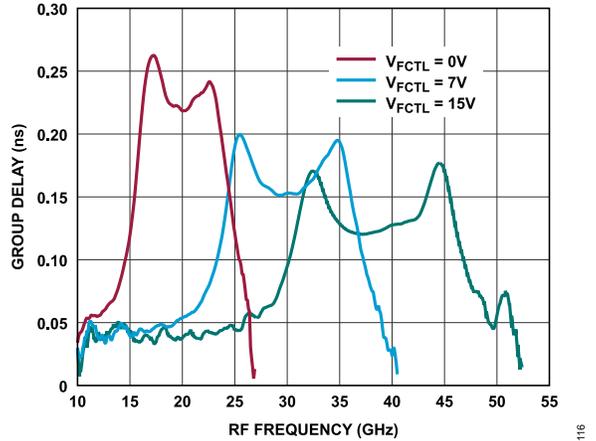


Figure 16. Group Delay vs. RF Frequency at Various Voltages

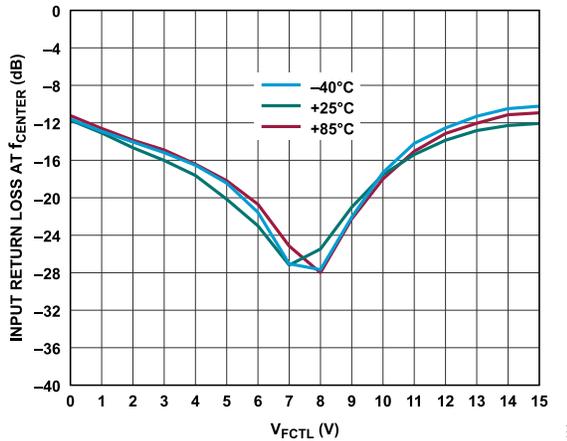


Figure 14. Input Return Loss at f_{CENTER} vs. V_{FCTL} at Various Temperatures

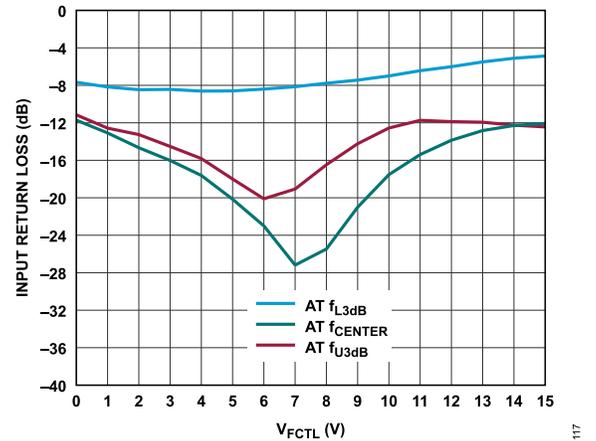


Figure 17. Input Return Loss vs. V_{FCTL} at Various Frequencies

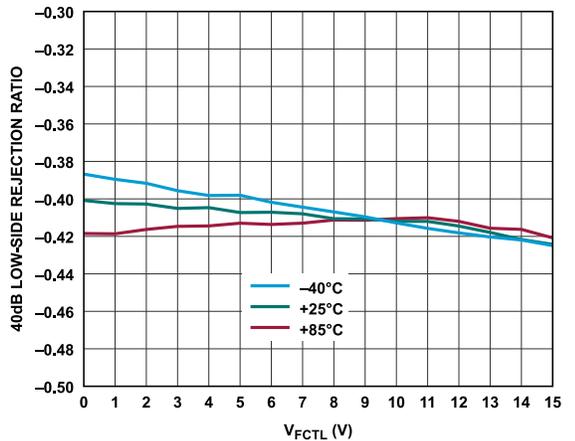


Figure 15. 40 dB Low-Side Rejection Ratio vs. V_{FCTL} at Various Temperatures

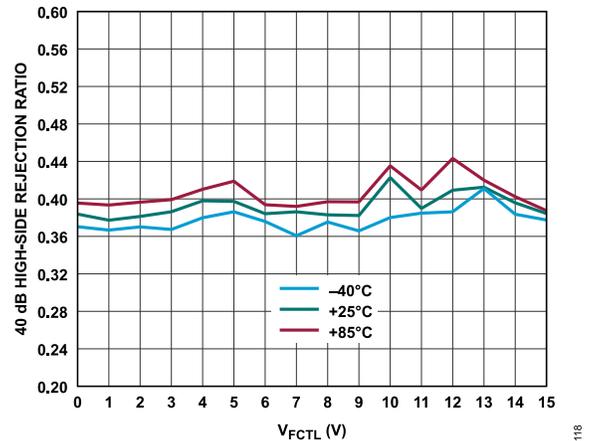


Figure 18. 40 dB High-Side Rejection Ratio vs. V_{FCTL} at Various Temperatures

TYPICAL PERFORMANCE CHARACTERISTICS

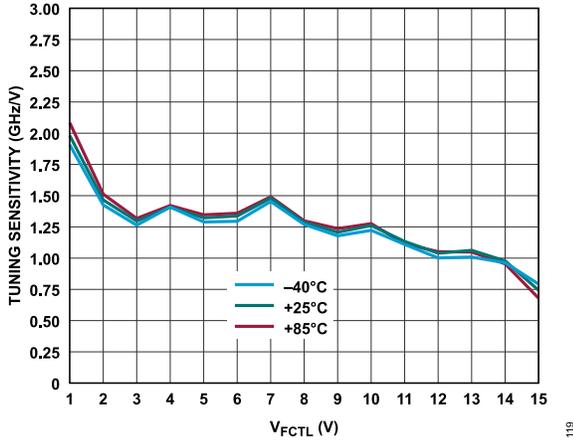


Figure 19. Tuning Sensitivity vs. V_{FCTL} at Various Temperatures

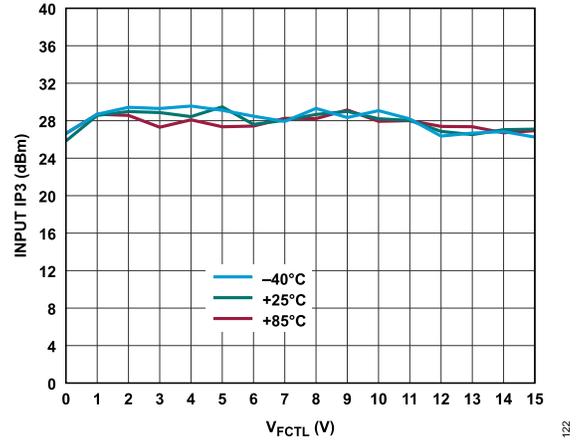


Figure 22. Input IP3 vs. V_{FCTL} at Various Temperatures

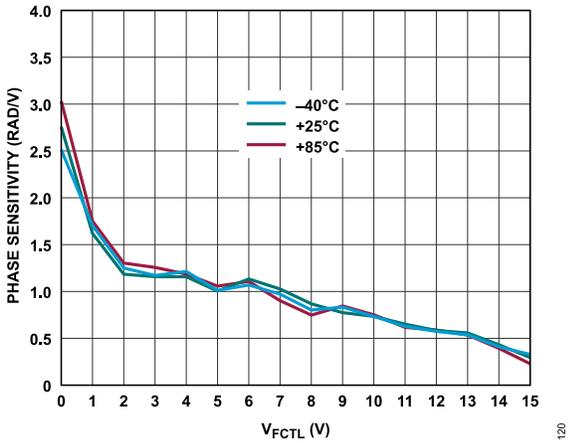


Figure 20. Phase Sensitivity vs. V_{FCTL} at Various Temperatures

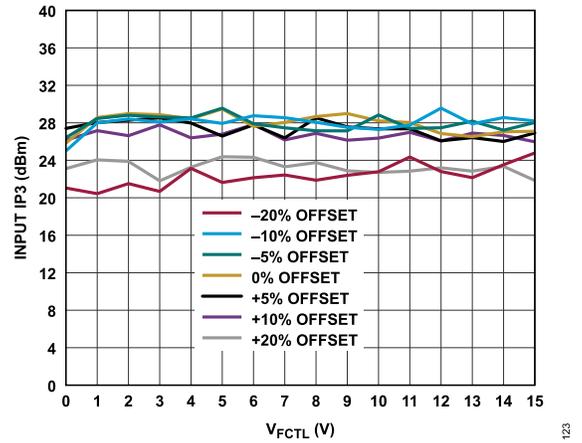


Figure 23. Input IP3 vs. V_{FCTL} at Various Frequency Offsets

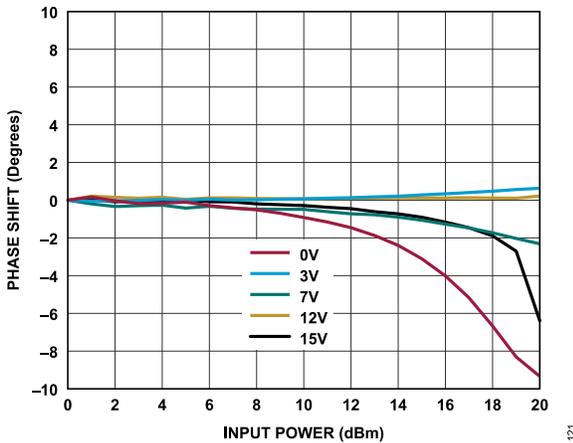


Figure 21. Phase Shift vs. Input Power at Various Voltages

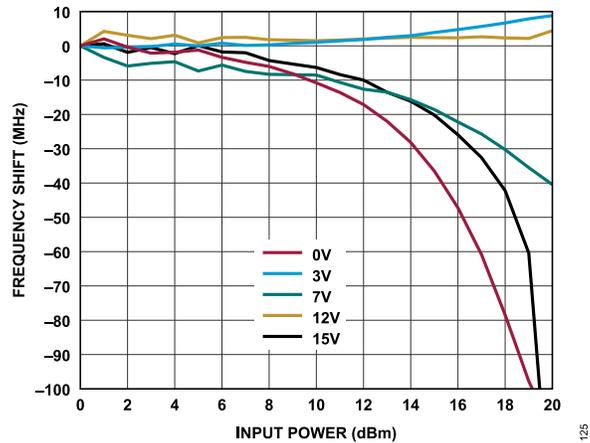


Figure 24. Frequency Shift vs. Input Power at Various Voltages

THEORY OF OPERATION

The ADMV8440CHIPS is a MMIC band-pass filter that features a user-selectable pass-band frequency. Varying the applied analog tuning voltage between 0 V and 15 V at V_{FCTL} varies the f_{CENTER} between 19 GHz and 38 GHz.

APPLICATIONS INFORMATION

FILTER ARCHITECTURE

The filter architecture of the ADMV8440CHIPS is considered a symmetrical design. Therefore, the RF1 and RF2 pads can be used interchangeably. The same pass-band response can be achieved regardless of which pad is used as the input and which pad is used as the output.

TYPICAL APPLICATION CIRCUIT

Figure 25 shows the typical application circuit for the ADMV8440CHIPS. The RF1 and RF2 pads are DC-coupled to ground and an external voltage must not be applied. Install 10 pF capacitors (C1 and C2) in series with the RF1 and RF2 pads to prevent any prestage or poststage interaction with the filter.

On the V_{FCTL} pad, the C3 decoupling capacitor is shown with 100 pF as the typical value. However, the selection of the C3 capacitor is determined based on the system design criteria for phase noise and tuning speed. That is, there is a baseband noise characteristic for a particular control voltage, which can translate into additive phase noise within the filter. Baseband noise on the control voltage can be minimized by capacitive means at the expense of voltage rise time, which impacts the tuning speed of the filter. Carefully consider the control voltage baseband noise and rise time performance to ensure that system performance metrics are met.

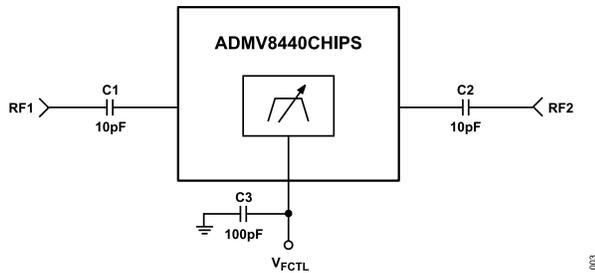


Figure 25. Typical Application Circuit

INPUT AND OUTPUT MATCHING CIRCUIT

To achieve good return loss, use a 60 fF shunt capacitance matching circuit at the input and output. Two possible matching circuits that can provide optimal performance include microstrip and ground signal ground (GSG), as follows:

- ▶ A matching circuit for a microstrip implementation can be achieved using a small amount of silver epoxy bonded onto the input and output RF transmission lines. Figure 28 shows an example of the microstrip implementation.

- ▶ A matching circuit for a GSG implementation can be achieved using a combination of ribbon bonds and metal trace on the input and output RF transmission lines. Figure 29 shows an example of GSG implementation.

For reference, Figure 30 and Figure 31 provide example dimensions for the microstrip launcher and the GSG launcher used in each implementation. When choosing an implementation, it is recommended to use similar dimensions.

Figure 26 and Figure 27 show the expected input and output return loss performance, respectively, for the two implementations.

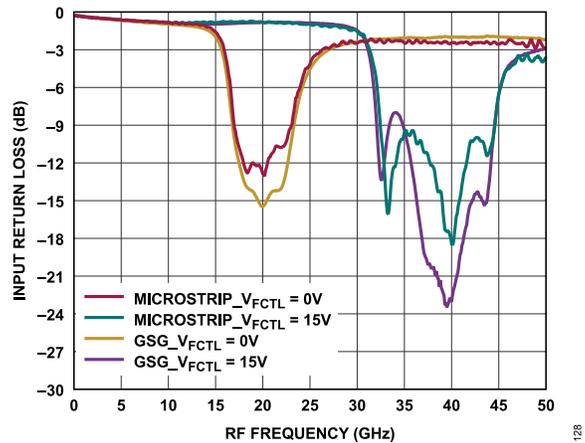


Figure 26. Input Return Loss vs. RF Frequency at $V_{FCTL} = 0\text{ V}$ and 15 V , with Matching Circuit

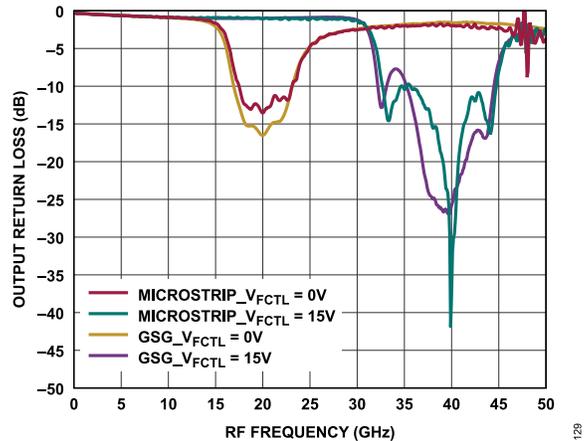


Figure 27. Output Return Loss vs. RF Frequency at $V_{FCTL} = 0\text{ V}$ and 15 V , with Matching Circuit

APPLICATIONS INFORMATION

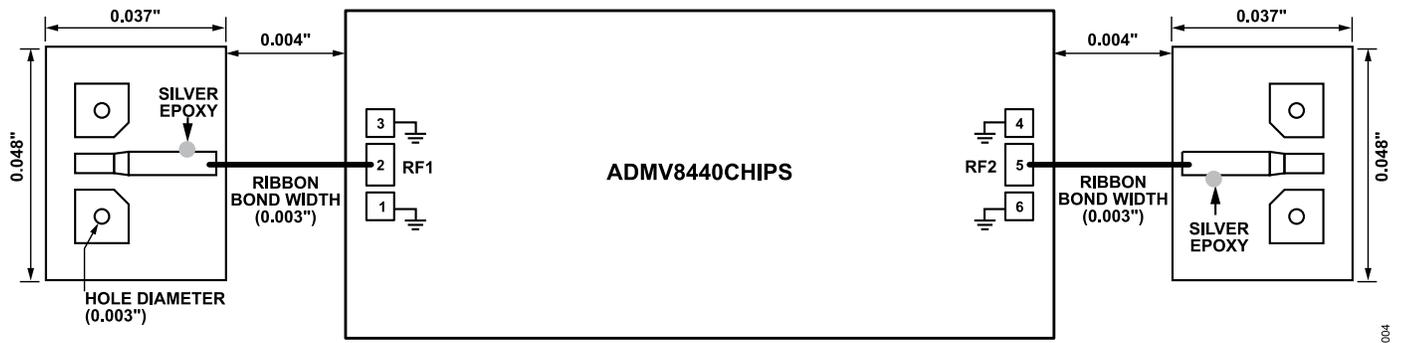


Figure 28. Matching Circuit Using Microstrip

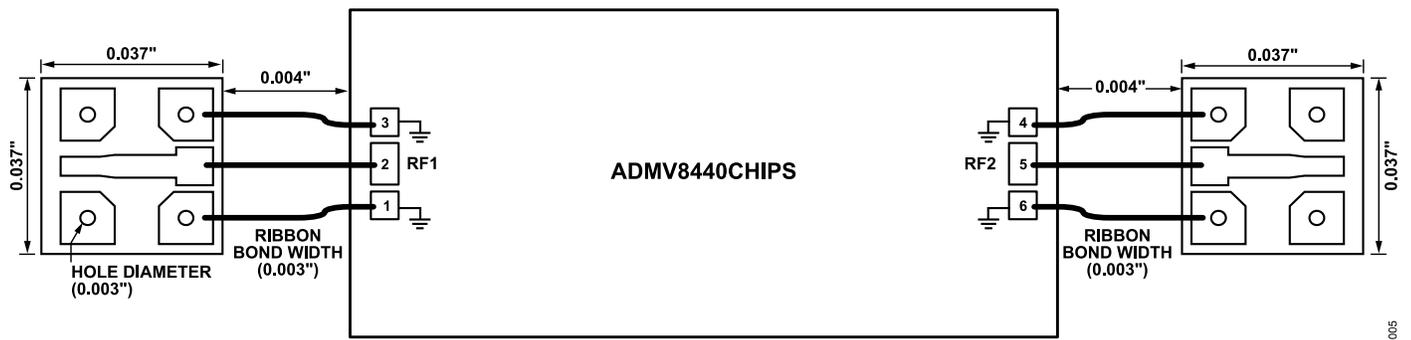


Figure 29. Matching Circuit Using GSG

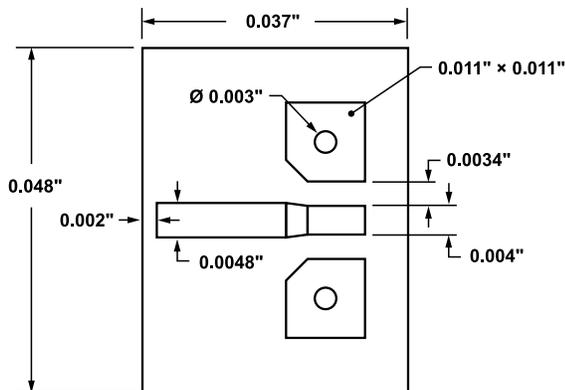


Figure 30. Microstrip Launcher Detailed Dimensions

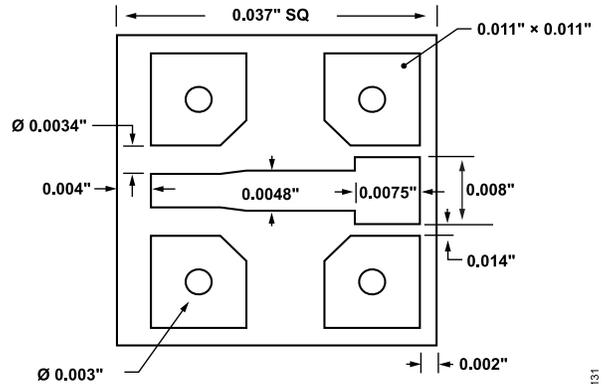


Figure 31. GSG Launcher Detailed Dimensions

APPLICATIONS INFORMATION

MOUNTING AND BONDING TECHNIQUES

Attach the die directly to the ground plane eutectically or with conductive epoxy. To bring RF to and from the chip, 50 Ω microstrip transmission lines on 0.127 mm (0.005") thick alumina thin film substrates are recommended (see [Figure 32](#)).

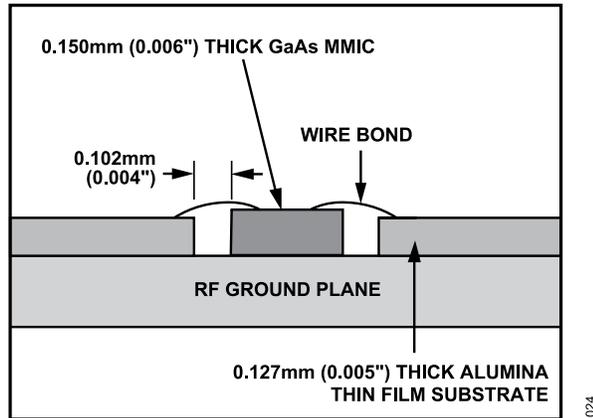


Figure 32. Bonding RF Pads to 5 mil Substrate

If using 0.254 mm (0.010") thick alumina thin film substrates, raise the die 0.102 mm (0.004") so that the surface of the die is coplanar with the surface of the substrate. A way to accomplish this is to attach the 0.150 mm (0.006") thick die to a 0.102 mm (0.004") thick molybdenum heat spreader (moly tab), which is then attached to the ground plane (see [Figure 33](#)). To minimize bond wire length, place microstrip substrates as close to the die as possible. Typical die to substrate spacing is 0.102 mm (0.004").

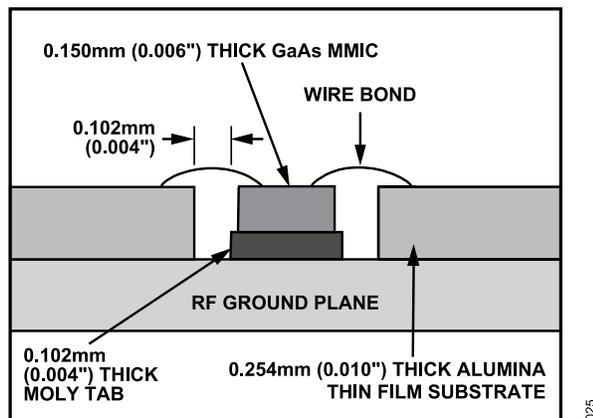


Figure 33. Bonding RF Pads to 10 mil Substrate

HANDLING PRECAUTIONS

To avoid permanent damage to the device, follow the precautions detailed in the [Storage](#) section, [Cleanliness](#) section, [Static Sensitivity](#) section, [Transients](#) section, and [General Handling](#) section.

Storage

All bare dice are placed in either waffle- or gel-based ESD protective containers and then sealed in an ESD protective bag for shipment. After opening the sealed ESD protective bag, store all dice in a dry nitrogen environment.

Cleanliness

Handle the chips in a clean environment. Do not attempt to clean the chip using liquid cleaning systems.

Static Sensitivity

Follow ESD precautions to protect against ESD strikes.

Transients

Suppress instrument and bias supply transients while bias is applied. Use shielded signal and bias cables to minimize inductive pickup.

General Handling

Handle the chip along the edges with a vacuum collet or with a sharp pair of bent tweezers. The surface of the chip has fragile air bridges. Do not touch the chip with a vacuum collet, tweezers, or fingers.

MOUNTING

The chip is back metallized and can be die mounted with gold (Au)/tin (Sn) eutectic preforms or with electrically conductive epoxy. The mounting surface must be clean and flat.

Eutectic Die Attach

An 80/20 gold and tin preform is recommended with a work surface temperature of 255°C and a tool temperature of 265°C. When hot 90/10 nitrogen(N)/hydrogen (H) gas is applied, the tool tip temperature must be 290°C. Do not expose the chip to a temperature greater than 320°C for more than 20 seconds. No more than 3 sec of scrubbing is required for attachment.

Epoxy Die Attach

Apply a minimum amount of epoxy to the mounting surface so that a thin epoxy fillet is observed around the perimeter of the chip when the chip is placed into position. Cure epoxy per the schedule of the manufacturer.

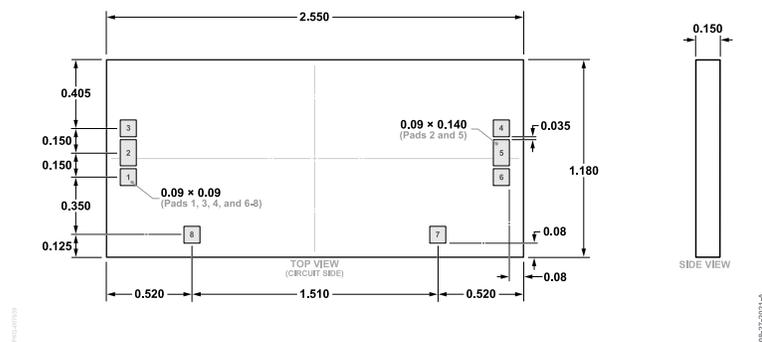
WIRE BONDING

RF bonds made with gold ribbon having 3 mil (0.076 mm) thickness are recommended for the RF ports. Alternatively, double 1 mil (0.025 mm) wire bond can be applied. These bonds must be thermosonically bonded with a force of 40 g to 60 g. DC bonds of 1 mil (0.025 mm) diameter, thermosonically bonded, are recommended.

APPLICATIONS INFORMATION

Create ball bonds with a force of 40 g to 50 g and wedge bonds with a force of 18 g to 22 g. Create all bonds with a nominal stage temperature of 150°C. Apply a minimum amount of ultrasonic energy to achieve reliable bonds. Keep all ribbon bonds as short as possible.

OUTLINE DIMENSIONS



**Figure 34. 8-Pad Bare Die [CHIP]
(C-8-27)**
Dimensions shown in millimeters

Updated: August 05, 2022

ORDERING GUIDE

Model ¹	Temperature Range	Package Description	Package Option
ADMV8440CHIPS	-55°C to +85°C	8-Pad Bare Die [CHIP]	C-8-27
ADMV8440CHIPS-SX	-55°C to +85°C	8-Pad Bare Die [CHIP]	C-8-27

¹ All models are RoHS compliant.